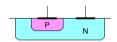
Components for Digital IC Design

Diodes and Bipolar Transistors

Diode







- Ideal structure 1D
- Real structure 3D
- Depth controlled implants.

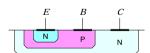
3001

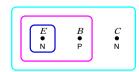
Components for Digital IC Design

Diodes and Bipolar Transistors

NPN Transistor





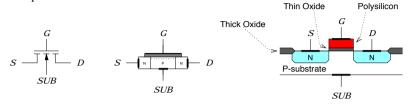


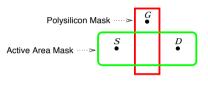
• Two n-type implants.

Components for Digital IC Design

MOS Transistors

Simple NMOS Transistor





3003

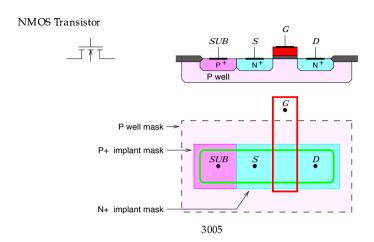
Components for Digital IC Design

Simple NMOS Transistor

- Active Area mask defines extent of *Thick Oxide*.
- Polysilicon mask also controls extent of *Thin Oxide* (alias *Gate Oxide*).
- N-type implant has no extra mask.
- It is blocked by thick oxide and by polysilicon.
- The implant is Self Aligned.
- Substrate connection is to bottom of wafer.
- All substrates to ground.
- Gate connection not above transistor area.
- Design Rule.

Components for Digital IC Design

MOS Transistors



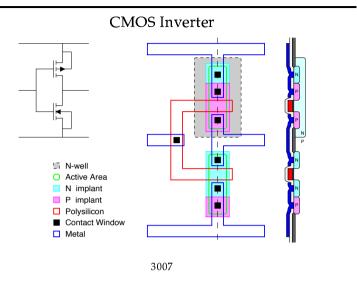
Components for Digital IC Design

NMOS Transistor

Where it is not suitable for substrate connections to be shared, a more complex process is used.

- Five masks must be used to define the transistor:
 - P Well
 - Active Area
 - Polysilicon
 - N+ implant
 - P+ implant
- P Well, for isolation.
- Top *substrate* connection.
- P+/N+ implants produce good *ohmic* contacts.

CMOS Process



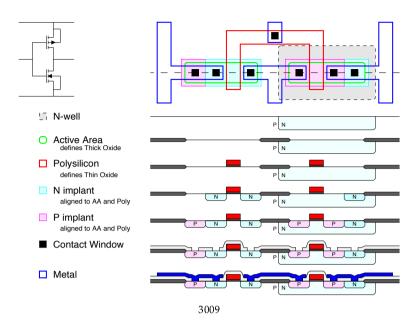
CMOS Process

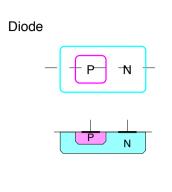
CMOS Inverter

- The process described here is an *N Well process* since it has only an N Well. P Well and Twin Tub processes also exist.
- Note that the P-N junction between chip substrate and N Well will remain reverse biased.

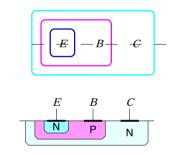
Thus the transistors remain isolated.

- N implant defines NMOS source/drain and PMOS substrate contact.
- P implant defines PMOS source/drain and NMOS substrate contact.

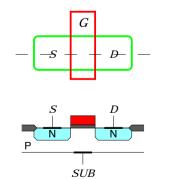


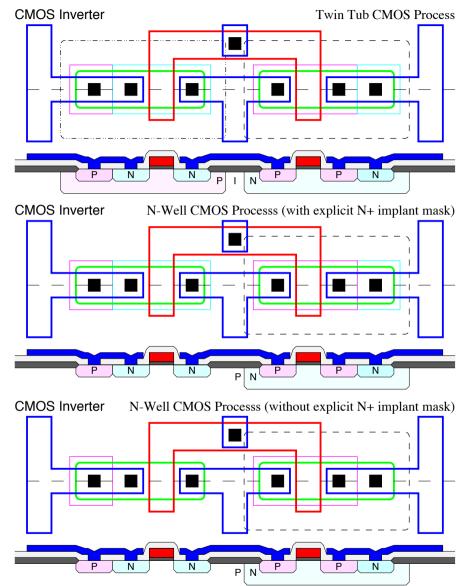


NPN Transistor



NMOS Enhancement transistor NMOS Process





Features may be determined by a number of masks e.g. NMOS source drain: ActiveArea AND NOT(NWell OR Poly OR PImplant)